

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/888,463	06/25/2001	Hermanus Leonardus Peek	NL 000359	8680
27082	7590 09/21/2004		EXAM	INER
DORSEY & WHITNEY LLP			FOURSON III, GEORGE R	
1001 PENNSY SUITE 400 SC	YLVANIA AVENUE, N.W.		ART UNIT	PAPER NUMBER
	ON, DC 20004		2823	

DATE MAILED: 09/21/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	09/888,463	PEEK ET AL.				
Office Action Summary	Examiner	Art Unit				
	George Fourson	2823				
The MAILING DATE of this communicate Period for Reply	ion appears on the cover sheet wi	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR THE MAILING DATE OF THIS COMMUNICA* - Extensions of time may be available under the provisions of 37 after SIX (6) MONTHS from the mailing date of this communication of the period for reply specified above is less than thirty (30) dated if NO period for reply is specified above, the maximum statutor Failure to reply within the set or extended period for reply will, I Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	TION. CFR 1.136(a). In no event, however, may a ration. ys, a reply within the statutory minimum of third y period will apply and will expire SIX (6) MON by statute, cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed o	n 27 August 2004.					
	☐ This action is non-final.					
3) Since this application is in condition for	· · · · · · · · · · · · · · · · · · ·					
Disposition of Claims						
4) □ Claim(s) 1 and 3-14 is/are pending in the 4a) Of the above claim(s) is/are with 5) □ Claim(s) is/are allowed. 6) □ Claim(s) 1 and 3-14 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction	vithdrawn from consideration.					
Application Papers						
9)☐ The specification is objected to by the Ex	kaminer.					
I0)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection	= · ·	• •				
Replacement drawing sheet(s) including the 11) The oath or declaration is objected to by	,	, , , ,				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for a) All b) Some * c) None of: 1. Certified copies of the priority doc 2. Certified copies of the priority doc 3. Copies of the certified copies of the application from the International * See the attached detailed Office action for	cuments have been received. cuments have been received in A ne priority documents have been Bureau (PCT Rule 17.2(a)).	pplication No received in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview S	Summary (PTO-413)				
Notice of Draftsperson's Patent Drawing Review (PTO-3) Information Disclosure Statement(s) (PTO-1449 or PTO Paper No(s)/Mail Date		s)/Mail Date nformal Patent Application (PTO-152) 				

The finality of the office action mailed 5/19/04 is withdrawn in view of applicant's argument regarding the teaching of Vadasz related to disclosure of LPCVD nitride formation. In view of ordinary usage in the art, the recitation of "low pressure chemical vapor deposition" is now not seen to be commensurate with CVD performed at a pressure less than atmospheric as disclosed by Vadasz.

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 1 and 3-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Stevens in view of Tobin et al and Gardner et al and optionally in view of Dyck.

Stevens is applied as stated in the office action mailed 5/19/04. The reference discloses the antiblooming implant to be to be useful in the event that the number of photocarriers generated by the incident radiation exceeds that of the storage capacity of the element, or pixel (col.1, lines 9-14). These excess carriers then spill over, or "bloom", into adjacent photosites thereby degrading the integrity of the image. This is a disclosure that the formation of the antiblooming implant to be preferable as opposed to necessary to produce a useful device and that one of ordinary skill in the art would have had a reasonable expectation of success of producing a useful image sensor by omitting the formation of the antiblooming regions. It would have been within the scope of one of ordinary skill in the art to omit formation of the antiblooming regions 22 and 32 with the expectation that the integrity of the image may be degraded as disclosed by Stevens et al. Disclosed examples and preferred embodiments do not constitute a teaching away from a broader disclosure or nonpreferred embodiments. In re Susi, 169 USPQ 423 (CCPA 1971).

"A known or obvious composition does not become patentable simply because it has been described as

Application/Control Number: 09/888,463

Art Unit: 2823

somewhat inferior to some other product for the same use." In re Gurley, 31 USPQ2d 1130, 1132 (Fed. Cir. 1994). A reference may be relied upon for all that it would have reasonably suggested to one having ordinary skill the art, including nonpreferred embodiments. Merck & Co. v. Biocraft Laboratories, 874 F.2d 804, 10 USPQ2d 1843 (Fed. Cir.), cert. denied, 493 U.S. 975 (1989). Even a teaching away from a claimed invention does not render the invention patentable. See Celeritas Technologies Ltd. v. Rockwell International Corp., 150 F.3d 1354, 1361, 47 USPQ2d 1516, 1522-23 (Fed. Cir. 1998), where the court held that the prior art anticipated the claims even though it taught away from the claimed invention. "The fact that a modem with a single carrier data signal is shown to be less than optimal does not vitiate the fact that it is disclosed." To further clarify, a prior art opinion that a claimed invention is not preferred for a particular limited purpose, does not preclude utility of the invention for that or another purpose, or even preferability of the invention for another purpose. The buried channel implant would then be the only implant of that conductivity type through gate dielectric 13.

In the event that the antiblooming implant is omitted the dosage of the implant forming the buried channel would be adjusted according to the teaching of col.3, line 65 – col.4, line 6.

Alternatively, Dyck et al discloses that CCD image sensors need not contain an antiblooming structure (col.1, lines 45-48). It would have been within the scope of one of ordinary skill in the art to combine the teachings of Stevens and Dyck et al to enable the formation of the image sensor of Stevens et al without formation of antiblooming structure 22 and 32.

Stevens does not disclose use of LPCVD to form the disclosed nitride layer of the gate dielectric.

Tobin et al discloses LPCVD nitride as a gate dielectric material (col.1, lines 34-54). Gardner et al discloses LPCVD nitride as a gate dielectric (col.3, lines 20-24). It would have been within the scope of one of ordinary skill in the art to combine the teachings of Stevens with the teachings of either Tobin et al

or Gardner et al to enable the formation of the nitride layer of the gate dielectric of Stevens to be performed.

Applicant argues that Stevens does not disclose implantation to form the buried channel through the gate dielectric 13. However, figure 2 shows such a step because the substrate comprises layer 13 (which can be ONO) and the arrows depict an implantation step. Note that layer 13 of figure 1 is the first dielectric layer formed and can remain as a final gate dielectric (col.3, lines 53-56).

Applicant argues that references drawn to gate dielectric formation for a MOSFET are not analogous to Stevens because Stevens is directed to CCD formation. However, the teachings of Tobin et al and Gardner et al are reasonably pertinent to the teachings of Stevens because both are directed to formation of a nitride layer which is used to insulate a gate, which controls a channel by field effect, from the channel.

Any inquiry of a general nature or relating to the status of this application should be directed to the Group Receptionist whose telephone number is (571) 272-2800. See MPEP 203.08.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to examiner George Fourson whose telephone number is (571)272-1860. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri, can be reached on (571)272-1855. The fax number for this group is (703)872-9306 and the customer service number for group 2800 is 571-272-2815. Updates can be found at http://www.uspto.gov/web/info/2800.htm.

George Hourson
Primary Examiner
Art Unit 2823

GFourson September 16, 2004